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Structural Defects Modulate Electronic and Nanomechanical Properties of 2D Materials

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ABSTRACT: Two-dimensional materials such as graphene and molybdenum disulfide are often subject to out-of-plane deformation, but its influence on electronic and nanomechanical properties remains poorly understood. These physical distortions modulate important properties which can be studied by atomic force microscopy and Raman spectroscopic mapping. Herein, we have identified and investigated different geometries of line defects in graphene and molybdenum disulfide such as standing collapsed wrinkles, folded wrinkles, and grain boundaries that exhibit distinct strain and doping. In addition, we apply nanomechanical atomic force microscopy to determine the influence of these defects on local stiffness. For wrinkles of similar height, the stiffness of graphene was found to be higher than that of molybdenum disulfide by 10–15% due to stronger in-plane covalent bonding. Interestingly, deflated graphene nanobubbles exhibited entirely different characteristics from wrinkles and exhibit the lowest stiffness of all graphene defects. Density functional theory reveals alteration of the bandstructures of graphene and MoS₂ due to the wrinkled structure; such modulation is higher in MoS₂ compared to graphene. Using this approach, we can ascertain that wrinkles are subject to significant strain but minimal doping, while edges show significant doping and minimal strain. Furthermore, defects in graphene predominantly show compressive strain and increased carrier density. Defects in molybdenum disulfide predominantly show tensile strain and reduced carrier density, with increasing tensile strain minimizing doping across all defects in both materials. The present work provides critical fundamental insights into the electronic and nanomechanical influence of intrinsic structural defects at the nanoscale, which will be valuable in straintronic device engineering.

KEYWORDS: 2D materials, wrinkles, defects, stiffness, strain, doping

The intriguing electrical, optical, and mechanical properties of 2D materials offer endless possibilities for high-performance devices. For instance, the virtue of electrons in graphene as 2D Dirac Fermions can be employed in supercapacitors¹ and photonic devices.² Also, in transition-metal dichalcogenide (TMD) structures such as molybdenum disulfide (MoS₂), the transition from indirect to direct bandgap facilitates the fabrication of biosensors and optoelectronic devices.³ To optimize device performance, single- to few-layer material is often required, which is conventionally attained by mechanical exfoliation (ME) or chemical vapor deposition (CVD) techniques.

The preparation techniques arise not perfect and inevitably results in a range of structural defects. Mechanical exfoliation

typically leads to a distribution of thickness and small lateral flake size (of a few microns), which not only precludes the feasibility of large-area devices but also creates prevalence of edge regions.⁴ At these regions, a deviation in coordination number in the lattice arrangement results in excess energy and stress compared to the flat counterparts.⁵ Under ambient conditions, airborne impurities may also be trapped at the

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Figure 1. AFM topography and Raman mapping of the structural defects in MoS₂ and graphene. (a) AFM morphology of wrinkled ME-MoS₂, (b) pit-holes in CVD MoS₂, (c) wrinkle in ME-Gr, (d) deflated graphene nanobubble with height ranging from 4 to 16 nm, and (e) grain boundary in CVD graphene on silica. The dashed rectangle represents the example of structural defect. All color scales shown are relative to zero height. (f, g) Raman spectra of MoS₂ and graphene samples. The presence of defects shifts the active Raman modes: E¹_{2g}, A_{1g} in MoS₂ and G, 2D modes in graphene.

edge, which alters local electronic (surface potential) and mechanical properties of the 2D materials.⁶ On the other hand, CVD often generates wrinkles and grain boundaries which originate from the polycrystalline nature of the monolayer and decrease the conductivity of graphene, for instance, by a factor of approximately three.⁷ Both fabrication methods followed by a transfer procedure induce wrinkles or nanobubbles owing to thermodynamic instability in 2D sheets⁸ and the difference in thermal expansion coefficient (TEC) between the 2D material and the substrate in CVD procedures.⁹

Peculiar properties emerge due to the lattice distortion in wrinkles, which can alter the surface area, conductivity, and molecular resonance states.^{4,7,8} While these changes are generally regarded as imperfections, they could possibly create opportunities for flexible devices and nanoelectronics.¹⁰ A comprehensive investigation into the modulation of electronic and nanomechanical properties is therefore essential to elucidate the constraints of each defect which can be considered during device design or exploited for potential applications. Mechanical strain is an important quantifiable property, which is responsible for Dirac cone shifting and Landau quantization in graphene¹¹ as well as bandgap widening in MoS₂.¹² Understanding the relationship between each type of structural defect and its associated strain is, therefore, critical to advances in the fields of optoelectronics and straintronics where strain engineering could lead to next-generation devices.¹³

Traditionally, the strain in 2D materials can be measured and evaluated experimentally by atomic force microscopy (AFM)¹⁴ or theoretically by elastic theories.¹⁵ The former method gives nanometre resolution but fails to quantify relatively small strain on pristine 2D flakes, while the latter is able to estimate small strain but is incapable of assessing complex structures.¹⁶ Thus, it is imperative to use an alternative and coupled experimental-numerical methodology to examine the minimal strain in nanoscale defects. Another crucial characteristic is doping, which represents the density of charge carriers n that shift the Fermi level and is found to be associated with electron–phonon coupling.¹⁷ It has a compelling contribution for fundamental research; for instance,

tuning the electron density can convert graphene into a superconductor,¹⁸ and therefore, an insight into defect-induced doping is vital.

Pioneering work was undertaken by Lee and co-workers,¹⁹ who developed a noninvasive strain and doping evaluation method for graphene at the nanoscale by Raman spectroscopy through correlation between shifts of the G (~ 1585 cm⁻¹) and 2D (~ 2680 cm⁻¹) modes. Under lateral compression (tension), the reduction (increase) in the interatomic distances leads to phonon stiffening (softening), and thus, a blue (red) shift of both peaks is observed.²⁰ Chemical bond modification by static charges and nonadiabatic coupling also shifts the peaks independently of strain.^{19,21} Hence, strain and doping can be regarded as two fundamental phenomena which are related to the Raman shift of G and 2D peaks, Pos(G) and Pos(2D), by a linear transformation, and can be determined using a correlation plot of Pos(G) and Pos(2D).¹⁹ The strain and doping in MoS₂ can also be quantitatively determined by the shift of its distinctive E¹_{2g} (~ 385 cm⁻¹) and A_{1g} (~ 403 cm⁻¹) modes representing the first-order Raman in-plane and out-of-plane phonon modes, respectively.^{22,23} Correlation analysis of the Raman shift of E¹_{2g} and A_{1g} peaks, Pos(E¹_{2g}) and Pos(A_{1g}), has enabled numerous studies to examine the influence of ripples,^{24,25} curvature,²⁶ heterostructures,²⁷ stacking, and domain size.²⁸

Nevertheless, Raman studies alone are insufficient for characterization of intrinsic defects due to limited spatial resolution. We thereby implement this compelling approach in combination with AFM studies of structural defects. Thus, information regarding doping, strain, and mechanical stiffness (*i.e.*, resistance to deformation) originating from the structural defects can be obtained, which is critical to fabrication of nanomechanical devices. This approach of extracting mechanical properties from AFM and mechanical strain and electronic doping from Raman mapping has previously only been applied to manipulated crumples,²⁹ which provides us with motivation in examining the inherent structural defects by this noninvasive technique.

In the present work, we identified common structural defects in mechanically exfoliated MoS₂ (ME-MoS₂), CVD-grown

Figure 2. (a–d) Raman mapping of ME-MoS₂ and CVD-MoS₂. The marked region represents the structural defects as wrinkles in ME-MoS₂ and pit-holes in CVD-MoS₂. (e, f) Raman mapping of ME-Gr structural defects; SEM micrograph and the I_D/I_G peak intensity ratio of two different types of wrinkles in ME-Gr as standing collapsed (marked by black color) and transitional-folded wrinkle (marked by red color). (g, h) SEM micrograph and the Raman map of I_D/I_G intensity ratio of six graphene nanobubbles of different geometry and height marked by dashed line circle. (i, j) Optical image and I_D/I_G peak intensity ratio of polycrystalline graphene on silica illustrating the networking of wrinkles.

MoS₂ (CVD-MoS₂), mechanically exfoliated graphene (ME-Gr), and CVD-grown graphene (CVD-Gr) by AFM and scanning electron microscope (SEM). Raman mapping was performed at the defective region along with the surrounding defect-free (DF) regions to deconvolve the effects of different types of nanoscale defects on the modulation of mechanical and electrical properties. Different phonon vibrational characteristics are used to distinguish defects from the DF counterpart. Subsequently, we measured strain and doping distribution (primarily from the underlying substrate) by monitoring the shift in Raman modes in graphene and MoS₂. Controlled AFM-based indentations were carried out which reveal a reduction in the stiffness of the defective regions as compared to the DF regions. Atomic-scale simulations of the distribution of strain along ripple defects, as an approximation to the experimentally observed defects, were achieved through density functional theory (DFT) and the subsequent effect on electronic properties was studied through band structure calculations. The critical insights presented in this work, combining nanoscale experimental and computational studies, will play an essential role in the future design and fabrication of 2D materials to evaluate and tune their application-specific mechanical and transport properties.

RESULTS AND DISCUSSION

Morphology of Structural Defects. Two-dimensional materials, either from industrially scalable CVD or laboratory-based ME procedures, are inevitably subject to structural defect formation. Here, we focus on different nanoscale line defects and pit-holes comprising out-of-plane deformation and broken lattice symmetry. Figure 1 shows nanoscale imaging through AFM and Raman mapping of structural defects of ME-MoS₂, CVD-MoS₂, ME-graphene, and CVD-Gr. The region marked by the dashed rectangle/line in Figure 1a–e shows illustrations of a standing collapsed wrinkle in ME-MoS₂, pit-holes in CVD-MoS₂, the transition from wrinkle in ME-graphene, and a nanobubble and a grain boundary in CVD-Gr,

respectively. The average thicknesses of ME-MoS₂ and CVD-MoS₂ are measured as 0.93 ± 0.20 and 0.67 ± 0.40 nm, respectively which indicates them to be single layer (see Supporting Figure S1a,b). Nevertheless, the presence of wrinkles and ripples in ME-MoS₂ and adsorbed airborne impurities in CVD-MoS₂ causes wide deviation from the average values. Wrinkles are generated in the 2D sheets due to interfacial compressive strain between the substrate and the physically deposited sheet. The release of compressive strain culminates in a buckled structure due to low bending rigidity of the thin sheet⁸ (see Supporting Figure S2 for the AFM micrograph, height profile, and adhesion force map).

The pit-holes in epitaxially grown MoS₂ are formed by etching of the silica substrate due to alkali metal (Na) used during fabrication.³⁰ The density of the pit-holes varies with concentration of Na⁺ precursor and the processing temperature in the CVD chamber. We do not observe the presence of wrinkles in CVD-MoS₂ due to its higher TEC (7.6×10^{-6} K⁻¹) than the underlying silica substrate (0.5×10^{-6} K⁻¹).^{31,32} During cooling in the fabrication process, MoS₂ contracts more than silica, leading to tensile strain which prevents wrinkle formation.⁹ The bending rigidity of graphene is more than 10 times lower than that of MoS₂,³³ and thus, a higher prevalence of wrinkles has been observed in the former. The trapping of gaseous molecules under the graphene layer in ambient conditions results in the formation of nanobubbles with varying height from 4 to 50 nm during heat treatment.³⁴ These distorted structures influence strain, doping, and stiffness in their extraordinary way which are investigated through Raman spectroscopy.

Raman Mapping of Structural Defects. The strain and doping contribution made by structural defects in MoS₂ and graphene are studied by Raman spectroscopy in ambient conditions, where the typical Raman modes of MoS₂ and graphene are shown in parts f and g, respectively, of Figure 1. Raman modes of MoS₂, E_{1g}, and A_{1g} are observed at 384 and 403 cm⁻¹ and are associated with in-plane and out-of-plane

Figure 3. Effect of the structural defects on strain and doping MoS₂. (a) Correlation plot of $\text{Pos}(E_{12g})$ versus $\text{Pos}(A_{1g})$ of ME-MoS₂. (b) Strain map of ME-MoS₂ showing the distribution of local strain from flat MoS₂ to the edge region. (c) Doping map of ME-MoS₂ displaying the spatial distribution of charge carrier density (n). (d) Correlation plot for CVD-MoS₂ for CVD/flat, pit-holes, and edge region. (e) Strain and (f) doping maps of epitaxially grown single-layer MoS₂ show edges and pit-holes (marked in circles), induced higher tensile strain, and wide distribution of charge carriers.

vibration, respectively.³⁵ Weakened interlayer interaction is observed through the phonon softening of A_{1g} mode in thinner MoS₂ sheets. A long-range Coulomb interlayer interaction is prevalent in thinner layers as observed through E_{12g} modes. Therefore, the difference in Raman shift between $\text{Pos}(E_{12g})$ and $\text{Pos}(A_{1g})$ is considered a parameter to determine the thickness of DF MoS₂ flakes. In ME-MoS₂ (Figure 2a,b), we observe the difference in Raman shifts $\Delta = \text{Pos}(A_{1g}) - \text{Pos}(E_{12g})$ to have values of 18, 22, and 23 cm⁻¹ for mono-, bi-, and trilayers, respectively.³⁶ The presence of structural defects alters this trend, which is illustrated by the Raman map of ME-MoS₂ and CVD-MoS₂ in Figure 2a,b and c,d, respectively. We record phonon softening of the E_{12g} mode at wrinkles in ME-MoS₂ and around pit-holes in CVD-MoS₂ as compared to the surrounding DF region, while a minimal shift is observed for A_{1g} mode. Thus, the presence of wrinkles in monolayer ME-MoS₂ displays the illusion of a bilayer. Similarly, the Raman modes in CVD-MoS₂ at pit-holes (marked by circles in Figure 2c,d) and edge regions deviate from DF counterparts. In graphene, D peak intensity (see Supporting Figure S3) and the intensity ratio I_D/I_G serve as indicators for Raman-active disordered structure and, hence, can be used to monitor the distribution of structural defects such as large wrinkles, edges (zigzag configuration), and damaged/deflated nanobubbles (Figure 2e–j). The D peak does not correspond to a zone center vibrational mode originated from the defects themselves but is attributed to activation of the A_{1g} breathing phonon mode at the K point with momentum ($q \neq 0$) due to the relaxation of the fundamental Raman selection rule.^{18,37} In

the pristine crystalline structure of graphene, $q \sim 0$ is conserved and the D peak is forbidden. It has been shown that the D peak and its overtone (2D) are susceptible to change in the electronic band structure.²⁰ The G peak (~ 1585 cm⁻¹) corresponds to the E_{2g} phonon mode, which is due to the stretching of sp^2 carbon in graphene. The shifts in $\text{Pos}(G)$ and $\text{Pos}(2D)$ Raman modes are sensitive to the different geometries of wrinkles and can, therefore, be used to distinguish them. For instance, distinct Raman signals from standing collapsed wrinkles, transitional-folded wrinkles, and folded wrinkles are observed; see Figure 2e,f and Supporting Figure S4 for a Raman map and SEM and AFM micrographs for a complete description. There is a phonon softening of $\text{Pos}(2D)$ for the standing collapsed structure and a phonon stiffening for the transitional-folded configuration, but both show redshifts in $\text{Pos}(G)$. Similarly, the blueshift in $\text{Pos}(2D)$ is also observed for CVD wrinkles (see Supporting Figure S5) as well as in deflated graphene nanobubble regions (see Supporting Figure S6), indicating the presence of compressive strain as compared to its surrounding DF regions.

Strain and Doping Contribution from Structural Defects. Raman shift measurements are applied to deconvolve strain and doping as described elsewhere;^{19,22} see Supporting Figure S7 for a description. Figure 3 illustrates the correlation plot, strain map, and doping map of monolayer ME-MoS₂ and CVD-MoS₂. In the correlation plot, the intersection coordinate of the strain and doping axis is assumed to be minimally strained and doped by the substrate and considered as a reference, which is taken from the average value of our

Figure 4. Effects of the structural defects on strain and doping graphene. (a) Correlation plots of Pos(G) versus Pos(2D) for ME-Gr. The spreading of data shown in orange is from DF flat graphene. The data from standing collapsed wrinkled area is shown in black, while orange data distribution represents transitional folding wrinkle. (b) Strain map of ME-Gr derived from Raman data and AFM topography (inset) show tensile and compressive strain from two different geometries of wrinkles. The regions marked with dashed rectangles are standing collapsed and transitional-folded wrinkles. (c) The doping map shows the distribution of charge carriers for two different geometries of wrinkles. Inset: schematic illustration of standing collapsed wrinkle and transitional-folded wrinkle. (d) Correlation plot of CVD graphene resembles ME-Gr in panel (a). (e) Strain map of the polycrystalline graphene shows compressive strain at wrinkles as compared to the flat region; some wrinkles are also showing tensile strain. (f) The carrier concentration in polycrystalline graphene shows the wide distribution of charge, where the wrinkle has higher n . (g) The correlation plot of the deflated graphene nanobubble shows low electron concentration and higher compressive strain than its surrounding flat graphene. (h) The strain map of the six nanobubbles on ME-Gr shows the distribution of compressive stress in the encircled region; white region is silica substrate and 2L-graphene. The inset is an AFM micrograph showing the shape and arrangement of the nanobubble density. (i) The doping map depicts lower n in the nanobubble region as compared to the surrounding flat graphene.

experimental ME-MoS₂ DF data and suspended graphene from elsewhere.¹⁹ The dissimilarity in reference selection approach arises from the different chemical composition between graphene and MoS₂. Graphene only comprises a single layer of carbon atoms, but MoS₂ comprises a S–Mo–S layer, which makes MoS₂ more prone to doping by ambient conditions. Therefore, there are no broadly accepted values for strain- and doping-free MoS₂, compared to both experimentally and theoretically reproducible values for suspended graphene. The deposition or growing of 2D sheets over silica substrates induces both strain and doping which may be discerned using the correlation plot. Any modified interaction between the 2D sheet and the substrate such as wrinkles, pit-holes, and edges can also be detected. The correlation plot of ME-MoS₂ reveals

a wide distribution of strain ϵ (−0.1 to +0.3%). The DF flat region shows a range of tensile and compressive strain from +0.15 to −0.1% as shown in black in Figure 3a. It indicates variable interfacial coupling between ME-MoS₂ and silica substrates even for the flat sheet. The strain map at Figure 3b is clearly showing the accumulation of the compressive strain at the central flat region (black, ϵ = −0.09 to −0.01%) which is gradually released at the wrinkled region (dark pink, ϵ = 0.08–0.14%) and at the edge region of the MoS₂ sheet (bright pink, ϵ = 0.14–0.27%). The appearance of the localized strain around the edge and the step-edge region could be related to the edge relaxation mechanism applicable for both armchair and zigzag configuration.³⁸ It includes the adjustment of bond length and bond angles of the edge atoms to minimize the

excess energy generated during mechanical exfoliation.³⁹ Recently, high-resolution analysis of MoS₂ edges reveals the adjustment of the terminal ends in the formation of concave and convex structure which can tune the strain field from compressive to tensile.³⁸ In the present investigation, the micron-scale Raman probe is not able to resolve the atomic configuration of the edge sheet, and thus, a high-resolution topographic image concurrent to elastic properties (by force–distance measurement) has been carried out over the relocated region of ME-MoS₂. The atomically resolved edge from AFM illustrates the stretched atoms of S–Mo–S bonds which is revealed by comparing with the unstrained MoS₂ (2 × 2 nm²) from DFT study and validated by the AFM line profile. We also observed that the nanoscopic edge region (up to displacement of 250 nm) has an out-of-plane distortion (~400 pm) as compared to the DF basal plane. There is a relative drop in the stiffness (up to 2–3%) from basal plane to the edge region also (see Supporting Information Figure S8). These findings indicate tensile strain at the edge of ME-MoS₂, which is consistent with the prediction by Tinoco and co-workers.³⁸

The wrinkled region in ME-MoS₂ of standing collapsed geometry (see profile from AFM at supplementary Figure S2) shows tensile strain. Local strain influences the carrier distribution in the MoS₂ sheet, and higher electron concentration at the edge region has been observed (Figure 3(c)). It shows the intrinsic tensile strain increases the mobility of the charge carrier. These effects are also observed in other TMDs at small external tensile strain due to incremental changes in the energy gap at the K and Q valleys.⁴⁰

Figure 3d shows MoS₂ epitaxially grown over silica with a tensile strain over the entire sheet in contrast to ME-MoS₂ and higher n , indicating stronger coupling with the substrate than ME-MoS₂. The presence of built-in tensile strain in CVD-MoS₂ is attributed to the mismatch in the thermal expansion between MoS₂ and silica substrate from 800 °C to room temperature resulting in tensile strain.⁹ At the pit-hole regions, the interaction between MoS₂ and silica is modified relative to the flat region. The pit-hole region can be considered as a circular trench where the MoS₂ sheet is bent around the circular ring that leads to an increase in tensile strain ranging from 0.01% to 0.07%. Unlike ME-MoS₂, the edge region in the CVD-MoS₂ sheet does not induce distinguishable strain (Figure 3e). Nevertheless, it shows a wide range of n in Figure 3f that might be due to different configurations of their terminal atoms (Mo, S/Mo, and S termination). It has been reported that these terminations have a different affinity toward airborne impurities that act as electron transfer site to/from adsorbed species.⁶

The correlation plot of Raman modes Pos(G, 2D) of graphene and its associated local strain and doping are given in Figure 4. ME-Gr shows a broad range of interactions with the silica substrate as revealed from the wide distribution of strain ϵ (−0.03 to +0.07%). The irregular conformation of graphene over the substrate is regulated by the adhesion forces between graphene and the substrate which result in the compressive strain as compared to free-standing graphene (intersection point of strain and doping axis). Thus, the appearance of ripples/wrinkles/nanobubbles in graphene is a result of balance between adhesion energy and bending energies. Generally, an excess length (2D material length compared to substrate length) of at least $L_m \sim 24(k/2\beta)^{1/2}$ is required for the transition from a ripple to a folded wrinkle (FW), where k

is the bending stiffness and β the binding (vdW) energy per atom thus defining a maximal height for a standing collapsed (SC) wrinkle of $H \sim L_m/2$.^{41,42} It has been observed that graphene SC wrinkle sustains its height easily up to 8.4 nm as predicted by $L_m \sim 16.3$ nm ($k = 1.4$ eV, $\beta = 40$ meV); after exceeding the critical height (nearly 8 nm),⁴³ it starts to bend toward the substrate, albeit not coupled. We refer to this intermediate geometrical state as a transitional-folded wrinkle (TFW). When the wrinkle height is significantly larger than the critical height, the wrinkle finally collapses into a FW, an architecture composed of 3N where N is the number of layers.⁴² Therefore, a single-layer graphene results in a strip of trilayer graphene with the modified vertical gap. This geometry alters the electrical and mechanical properties and the interfacial interaction.⁴⁴ We deconvoluted the strain and doping in the wrinkled structure up to its TFW state as the parameters used in the correlation plot is limited to a single layer of graphene only verified by monitoring ($I_{2D}/I_G > 1$). The completely folded multilayer graphene revealed by the Raman spectrum $I_{2D}/I_G < 1$ requires distinct parameters; see Supporting Information Figure S4 for different shapes of transformed wrinkles. The strain map (Figure 4b) and doping map (Figure 4c) for ME-Gr illustrate two distinct geometries of wrinkles, SC and TFW wrinkles, which are also confirmed from AFM topography (inset Figures 4b and S4). The transformation of graphene from SC architecture into TFW geometry results in a transition of Pos(2D) from phonon softening mode to stiffening and, consequently, a transition of strain from tensile to compressive (Supporting Figure S4). This transformation also influences the doping as follows: TFW ($n \approx -1.1 \times 10^{12}$ cm^{−2}), SC wrinkle ($n \approx -2.6 \times 10^{12}$ cm^{−2}), and DF flat region ($n \approx -4.2 \times 10^{12}$ cm^{−2}). It can be interpreted that prohibition of p-doping occurs when graphene buckles into the SC structure, and this prohibition is strengthened when the wrinkle develops into the TFW architecture. These results are also in good agreement with the high-resolution Kelvin probe force microscopy (KPFM) studies that showed higher electron concentration in the transitional-folded graphene as compared to the standing collapsed wrinkle (see Figure S9). Long *et al.*⁴⁵ have observed through KPFM studies that the vertical gap between graphene and silica substrate can influence the doping in the graphene, which is distinct between SC and FW geometry.

The scatter in the correlation data of CVD-Gr on silica resembles the ME-Gr distribution (see Figure 4d). Nevertheless, the strain and doping maps illustrate higher density of wrinkles/ripples in the CVD system than ME-graphene. It reveals several categories of wrinkles that shows tensile and compressive strain. The region has overcrowding of wrinkles that leads to their merging at the junctions, which enhances the structural disorder as indicated by the I_D/I_G ratio (0.98) and induces compressive strain ϵ up to (−0.051%) and small magnitude of $n \approx -1.23 \times 10^{12}$ cm^{−2} (see Figures 2i,j and 4e,f). The $\Delta n \approx 2.18 \times 10^{12}$ cm^{−2} compared to the basal plane being positive implies graphene is less coupled with the substrate and prohibits p-doping. These characteristics are similar to the folded geometry of wrinkles in ME-Gr.

The grain boundary is another line defect in polycrystalline graphene; we performed Raman mapping of a perimeter around a single grain which can provide useful information regarding grain boundaries (see Supporting Figure S10). This region exerts the highest compressive strain as compared to wrinkles and exhibits higher n . The grain boundary comprises

Figure 5. Contribution of the structural defects: (a) Correlation between the relative strain and relative doping from surrounding DF in MoS₂ and graphene. The intersection of solid lines shows the coordinates of zero change in doping and strain. The dashed lines indicate the trend in the change in carrier concentration with increasing tensile strain. Normalized stiffness (%) of different defects of (b) MoS₂ (edge, hole and wrinkle) and (c) graphene (edge, wrinkle, and nanobubble) compared to the flat region. The uncovered data are from standing collapsed wrinkle; data lies in the violet-colored region are from folded wrinkle; the blue shaded region shows a deflated nanobubble and yellow shaded region shows an inflated nanobubble. (d) DFT calculation of bond length and ripple height across a graphene monolayer defect (e). Bandgap (eV) versus height (nm) of defected MoS₂. The bandgap is modified in MoS₂ due to buckling at the defect and induces a direct-to-indirect transition at higher strain. Inset shows the schematic diagram of the band structure of unstrained MoS₂.

local stitches of two grains attached to the substrate, unlike wrinkles which induce a vertical gap; therefore, the grain boundary is influenced by the underlying substrate to induce compressive strain. It has been reported through atomistic simulation that the stitching angle between adjacent grains can vary electron concentration and is found to be lowest for $\theta = 0^\circ$ and maximum for $\theta = 30^\circ$.⁴⁵

Graphene nanobubbles are inflated formations due to trapped molecules and appear in different shapes such as spherical caps⁴⁶ and trigonal⁶ and pentagonal geometry (see inset Figure 4h). These structural defects are less prevalent than wrinkles and grain boundaries. We did not find any nanobubble formation in our ME-MoS₂, but six nanobubbles over an occupied surface area of $\sim 2.25 \times 2.8 \mu\text{m}^2$ have been observed in ME-Gr. The tensile strain induced by the pressure inside the individual nanobubble is reported up to 0.37% as measured by AFM and Raman spectroscopy.⁴⁷ Nevertheless, deflated graphene nanobubbles (see Supporting Figure S11 for topography) behave differently and exert compressive strain (-0.079%) and lower n . It is worth noting that compressive strain is generated from a region of six deflated nanobubbles as marked by a dashed circle in Figure 4h. The present investigation is limited to resolve the contribution from each nanobubble since the diameter of the Raman probe is greater than the defect size (spot size 760 nm and lateral resolution ~ 240 nm). Thus, the measured compressive strain and n (Figure 4i) are the accumulation of six nanobubbles. The AFM profile has been used to measure the strain (ϵ_{AFM}) for the deflated nanobubble. It is found that few partially deflated individual nanobubbles exert tensile strain (ϵ_{AFM}) up to 0.08% as compared to DF. Still, some nanobubbles induce significant compressive strain ($\epsilon_{\text{AFM}} = -0.37\%$) as compared to inflated nanobubbles due to reduction in the perimeter for the latter.

By virtue of the correlation plot, strain map, and doping map in Figures 3 and 4, we have demonstrated the deconvolution of the absolute strain and doping of each structural defect with respect to the no-strain, no-doping coordinate. Nevertheless, it is also crucial to compare the interaction of each defect with respect to its nearby defect-free surrounding region (relative strain and doping) to provide additional information regarding the direct influence by the defect. This comparison can be drawn at Figure 5a and in the Supporting Information at Table S1 where we subtract the absolute strain and doping of the DF from that of the defect. While defects in MoS₂ are predominantly under tensile strain and all reduce carrier density, this reduction in electron concentration is compensated by increasing strain. Conversely, defects in graphene in general increase the carrier concentration compared to the surrounding DF region, but this surge diminishes with increasing strain. It indicates that for both graphene and MoS₂ the change in carrier concentration (Δn) is reduced with increasing tensile strain. The overall trend also indicates that edges are prone to doping than strain, while wrinkles in 2D materials contribute heavily to strain. The graphene nanobubble behave exceptionally in electronic modulation, and thus, introducing nanobubbles in scalable graphene sheets (*i.e.*, CVD-Gr) may be promising defects to engineer for straintronics.

Mechanical Stiffness of the Structural Defects. The in-plane stiffness is lower at the structural defects as compared to the surrounding DF regions owing to out-of-plane distortion in the lattice (see Supporting Figure S12 for details). We observed a higher indentation depth (δ^3 vs force) at the

structural defects as compared to the DF, which indicates a drop in stiffness. It is suggested that indentation depth required to puncture a suspended sheet is around 50 nm for MoS₂ and ~ 150 nm for graphene.⁴⁸ We limit our imposed displacement ($\delta \approx 5$ nm) so to have elastic deformation for both tip apex and the sample. The normalized drop-in stiffness (%) of structural defects for MoS₂ is shown in Figure 5b and for graphene in Figure 5c. In MoS₂, the lowest values of elastic stiffness (*i.e.*, 40% reduction) are measured from the wrinkle of height up to 2.9 nm, while the graphene wrinkle is relatively stiffer by a factor of 2.3 at a similar height. This is due to the higher intrinsic bending stiffness of graphene (350 ± 50 N/m) than MoS₂ (180 ± 60 N/m), owing to strong covalent carbon–carbon bonds as compared to the polar covalent S–Mo bond, respectively.⁴⁸ It is reported that out-of-plane deformation brings down the stiffness dramatically in a nonlinear fashion in relation to strain and amplitude of the buckled structure.⁴⁹ Generally, the bending rigidity of 2D material is defined through the compliance of in-plane stiffness and the energy-related out-of-plane formation. In particular, for graphene as a thin atomic layer, the system becomes highly anharmonic during out-of-plane deformation under the influence in-plane stress.¹⁴ For other 2D materials, the out-of-plane deformation (such as ripple and wrinkle) can be explained through its bending rigidity. Nevertheless, it is the scale of deformation (l_{anh}) that can decide the contribution from in-plane stiffness and bending rigidity to the elastic energy of the 2D material. It is expected that the ability to achieve in-plane stress from bending rigidity in graphene is higher than MoS₂ due to difference in the anharmonic scale of deformation (defined as square root of the ratio of the Young's modulus over the bending rigidity) of graphene (0.4 nm) and MoS₂ (between 0.4 and 1 nm). Therefore, the capability to transfer stress in graphene could be higher than MoS₂ of similar geometry.¹⁴

The stiffness of the inflated graphene nanobubble (20–50 nm height, marked by yellow color) drops up to 17%–30% from its surrounded DF region (see Figure 5c). After deflation (blue), the stiffness further drops to 50% due to the release of internal pressure from trapped gases. The release of trapped gases causes the distorted lattice to behave differently from the wrinkles for strain and doping as confirmed by Raman spectroscopy. The aspect ratio (height over in-plane diameter, h/d) can explain the interplay between van der Waals and elastic energies of nanobubble-shaped graphene. The reduced (increased) aspect ratio induces tensile (compressive) strain; see Supporting Information Figure S12b. The drop in the stiffness for various aspect ratios, where the aspect ratio of stiffer shapes has been measured around 6×10^{-2} , suggesting that trigonal- and pentagonal-shaped graphene nanobubbles are stiffer.

First-principles density functional theory (DFT) is implemented using the ripple structure in graphene and MoS₂ as an approximation to the larger amplitude experimentally observed wrinkles and nanobubbles. The interaction of flat MoS₂ and the graphene monolayer with the silica substrate (as α -quartz SiO₂) is investigated in different configurations as fully reconstructed and partially exposed dangling bonds through hydrogen passivation; see Supporting Figure S13 for details. The choice of α -quartz SiO₂ is due to its stable crystalline phase at ambient conditions. We observed p-doping in adsorbed graphene and MoS₂ monolayer over dangling oxygen bonds at the SiO₂ interface. Additionally, periodic supercells of

graphene and MoS₂ are constructed as in Figure S14a,b, wherein the unit cell is repeated a number of times in the armchair direction. A net compression is applied to the cell, which is divided into two regions, labeled as I and II for DF and rippled regions, respectively. In region I, the atoms are constrained to remain flat, such that the out-of-plane force component is set to zero during relaxation, while in region II, all atoms are allowed to fully relax. Upon structural relaxation, the resulting strain is accommodated through the out-of-plane buckling in the delaminated region; see Supporting Figure S14c,d for strain–height and curvature–strain correlations. The strain accommodation across the defected cell was then analyzed by extracting the variation in bond length with increasing ripple height, while electronic properties have been examined through band structure calculations. Our simulations indicate that the net bond compression depends upon the orientation of individual bonds with respect to the applied strain (further details regarding this and boundary conditions across the flat regions are provided in Supporting Information Figure S15).

The exceptional rigidity of monolayer graphene seen in our experiments is also evident in the theoretical calculations. For both materials, the bond strain across a defect is generally tensile (for more details, see Supporting Figure S16), while the change in bond length across graphene ripples does not exceed 0.3% for any height, as in Figure 5d. In contrast, deformed MoS₂ shows more exaggerated distortion of the bonds over a buckled region, with a larger variation in the Mo–Mo (~0.8%) and Mo–S (~2–3%) bond lengths at equivalent equilibrium heights, a fact which we attribute to the stronger covalent C–C bond of graphene. The bond lengths in the vicinity of a buckled region of MoS₂ demonstrate both the larger distortion of the Mo–S bond length and the asymmetry in this distortion, which is alternately compressive or tensile dependent on the relative orientation of the Mo and S atoms; see Supporting Figure S14b.

Band structure calculations of defective MoS₂ show that the inhomogeneous variation in bond length across a ripple also has a pronounced effect on its electronic properties due to the change in the length and angle of the Mo–S bonds, as shown in Figure 5e. At small equilibrium ripple heights, corresponding to less applied strain, buckling results in a moderate increase in the direct bandgap of a MoS₂ layer, while at larger heights (>1 nm) there is a systematic drop in the band gap and a transition from a direct to an indirect gap semiconductor (see the systematic band gap transition in Figure S17). The transition of the Λ valley in the conduction band to a lower energy than the K valley is responsible for this conversion of direct to indirect band gap.⁵⁰ This effect is also observed in the photoluminescence which decreases dramatically under tensile strain. This transition has been observed for both compressive and tensile strain in the monolayer of MoS₂. As in the case of ripple (for tensile strain), there is a transition of the valence band maximum from (K) to (Γ) valley.⁵⁰

CONCLUSION

Here, we have addressed the contribution of structural defects generated during fabrication and transfer of 2D materials over silica substrates to the electronic and nanomechanical properties of the materials themselves. By monitoring the morphology and Raman modes of graphene and MoS₂, we observed that the geometry of structural defects plays an essential role in the strain, doping and mechanical stiffness in

the studied 2D materials. The physical deposition of graphene and MoS₂ have compressive strain from the silica substrates at the defect-free regions, which is effectively released at wrinkles with a standing-collapsed geometry. Nevertheless, the other geometrical architectures of folded wrinkles, grain boundaries or deflated nanobubbles exert higher compressive strain as compared to surrounding DF graphene. The substrate also acts as a dopant to the 2D sheets, which varies at the defect center. Unlike ME procedure, CVD-MoS₂/silica induces tensile strain in the TMD sheet, the edges of the MoS₂ sheet have a broad range of n depending on the terminal ends of edge atoms and adsorption of airborne impurities. The stiffness of out-of-plane architecture of 2D layers steeply decreases with the amplitude of the buckled structure until the internal pressure regulates the resistance against mechanical deformation as in the case of inflated graphene nanobubbles. The graphene wrinkles are found to be stiffer than MoS₂ of similar geometry due to accumulation of higher strain accommodation in the MoS₂ as revealed by DFT calculations. Associated to these structural changes, we see modulation of the size of the band gap due to the defect and a transition from direct to indirect gap at higher strains in MoS₂. This approach allows us to make important intuitive observations about structural defects such as wrinkles exhibiting significant strain but minimal doping and edges exhibiting minimal strain but significant doping. In addition, defects in graphene predominantly show compressive strain and increased carrier density while defects in MoS₂ predominantly show tensile strain and reduced carrier density. Furthermore, increasing tensile strain is found to decrease doping across all defects in both materials. The presented work unravels path for device performance based on straintronics and defect engineering.

MATERIALS AND METHODS

Sample Fabrication. ME-MoS₂ graphene is transferred to a silica substrate with 300 nm thickness of oxide. It is then cleaned in ultrasonic bath for 30 min in 2-propanol and subsequently deionized water, and then heated in vacuum oven 200 °C for 3 h to remove organic impurities. CVD graphene is commercially obtained from Graphenea (Graphenea, Inc., Spain). CVD-MoS₂ crystals were grown by employing the fabrication method reported in the literature.⁵¹ In brief, Si wafers with a 90 nm thick SiO₂ layer were spin coated with an aqueous solution of 2 mg/mL NaMoO₄. Subsequently the wafers were placed in a two-zone high temperature furnace. The main zone (containing the substrates) was heated to a growth temperature of 750 °C with a rate of 10 °C/min. When the main zone reached the growth temperature, the second zone located upstream and containing a quartz crucible loaded with 2 g of S was heated to 230 °C. Both zones were kept at these temperatures for 15 min, and afterward, the tube was removed from the furnace and allowed to cool to room temperature. It is worth noting that selection of temperature is pivotal to control the “pit-holes” structural defect; even reduction of temperature by 50–100 °C can alter the density of pit-holes.

Raman Spectroscopy. Raman spectroscopy is performed by Renishaw inVia confocal Raman microscope with 532 nm laser (type: solid state, model RL53250) and 1800 mm⁻¹ grating in 100× magnification. Details about peak position accuracy is given in the Supporting Information in Figure S18. The Raman spectra for graphene samples were measured at 1.5 mW of power, while those of MoS₂ samples were measured at 0.15 mW of power for a duration of 1 s. The output power of the laser is separately monitored by a power meter (model: Gentec, PH 100-Si-HA-D0). The effect of the laser is separately studied over DF ME-MoS₂ and ME-Gr, and no overheating effect has been observed in terms of shifting of Raman peak positions. The peak intensity and peak position are determined by Lorentz curve fitting.

AFM Characterization. AFM characterization is carried out by Bruker Dimension Icon with PF-QNM (PeakForce-Quantitative NanoMechanical) mode, where topology, adhesion, and stiffness are measured on a single acquisition. Cantilevers are calibrated by preceding thermal tune for resonance frequency and stiffness, which are measured as 535 kHz and 200 ± 10 N/m, respectively, for stiffness measurement as well as 0.4 N/m and 70 kHz for topology and adhesion measurement. Kelvin Probe force microscopy (KPFM) was carried out by AFM-Bruker Dimension Icon at ambient condition over antivibrant stage. Contact potential difference (CPD, mV) was measured from advanced operation mode of Peak-force KPFM using a two-pass technique mode. In the first pass, the tip was softly (<1 nN) tapped on top of the sample to gather topographical data. In the second pass, the same scanning line, the cantilever was lifted from the surface up to 10 nm distance to collect CPD data. Silicon–nitride probe model: PFGNE-AL, tip diameter around 5 nm, and stiffness 0.8 ± 0.2 N/m was used for the investigation. Thermal tune calibration was performed before to monitor the stiffness of the cantilever. Freshly cleaved graphite (HOPG, WF = 4.66 eV) was used to measure the WF of tip WF (sample) = WF(tip) – eV(dc). The same relation is also used to measure the WF of the sample.

Scanning Electron Microscopy. Scanning electron microscopy (SEM) is operated by Zeiss SIGMA field emission gun with working distance of 2 mm and an accelerating voltage of 1 kV.

DFT. First-principles DFT simulations have been performed using the Quantum Espresso package.^{52,53} Vanderbilt ultrasoft Perdew–Burke–Ernzerhof (PBE) pseudopotentials are used to model all atomic species,^{54,55} and an energy cutoff of $E_{\text{cut}} = 40$ Ry is found to achieve high convergence. A $5 \times 5 \times 1$ k -point grid has been used for calculations of monolayer-SiO₂ adsorption, while a $5 \times 1 \times 1$ k -point sampling is applied to the rippled supercells, each giving an overall convergence to within 0.1 meV/atom of the more highly converged calculations. The van der Waals interaction is modeled using the optB86b-vdW functional, as implemented in Quantum Espresso. All Brillouin-zone integrations are performed on a Γ -centered mesh generated according to the Monkhorst–Pack method and a Gaussian smearing of width 0.01 eV is applied. Structures are optimized until the force on all atoms is less than 1×10^{-3} eV/Å, and the energy change is less than 1×10^{-4} eV. Electronic band structures are calculated using a more highly converged $15 \times 2 \times 1$ k -point grid.

ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge at <https://pubs.acs.org/doi/10.1021/acsnano.0c06701>.

Thickness measurements of graphene and MoS₂ (S1). Adhesion force map of the structural defects in concurrent with topography (S2). Raman spectra and mapping of ME and CVD graphene (S3–S6). Correlation plot measurement using Grüneisen parameters and strain rate of MoS₂ and graphene to generate strain and doping map (S7). Physical and elastic properties of the MoS₂ edge (S8). Surface potential map of wrinkle in ME-Gr (S9). Raman mapping of grain boundary in CVD-graphene showing strain, doping, and ID/IG ratio (S10). AFM image of inflated and deflated individual nanobubble (S11). Force–distance spectra and stiffness map of graphene and MoS₂ (S12). DFT calculations showing electronic band structure, height-strain relation and accumulation of strain at the rippled structure (S13–17). Determination of spectral accuracy using Si wafer as reference (S18)(PDF)

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800 Notes

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